



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:

Ilya Karpov et al.

Serial No.: 10/822,361

Filed: April 12, 2004

For: Fabricating Deeper and Shallower  
Trenches in Semiconductor Structures

§ Art Unit: 2814  
§  
§ Examiner: Long Pham  
§  
§ Docket: ITL.0835D1US  
§ P14730D  
§  
§ Assignee: Intel Corporation  
§  
§ Conf. No. 3077

Mail Stop RCE  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**AMENDMENT ACCOMPANYING REQUEST FOR CONTINUED EXAMINATION**

Sir:

Please consider the following amendments and remarks.

Date of Deposit: April 4, 2006

I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as **first class mail** with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

  
Nancy Meshkoff